

**PATENT ABSTRACTS OF JAPAN**

(11)Publication number : 2003-306765

(43)Date of publication of application : 31.10.2003

(51)Int.Cl.

C23C 14/34

C22C 5/06

G11B 7/24

G11B 7/26

(21)Application number : 2002-114738

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(22)Date of filing : 17.04.2002

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**(54) SILVER ALLOY SPUTTERING TARGET FOR FORMING REFLECTION FILM OF OPTICAL RECORDING MEDIUM AND REFLECTION FILM FORMED BY USING THE TARGET****(57)Abstract:**

**PROBLEM TO BE SOLVED:** To provide a silver alloy sputtering target for forming a reflection film in optical recording media such as optical recording disks (CD-RW (compact disk-rewritable), DVD-RAM (digital versatile disk-random access memory) and DVD-9), and to provide a reflection film which is formed by using the target.

**SOLUTION:** The silver alloy sputtering target consists of a silver alloy having a composition of, by mass, 0.01 to 5% Ge, and further of one or more kinds of metals selected from Co, Fe, Ni, Nd and Ir, and the balance Ag. The reflection film is formed by using the target.

**LEGAL STATUS**

[Date of request for examination]

01.02.2005

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

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